

Title (en)

METHOD FOR THE TREATMENT OF A PHOTOCONDUCTOR

Publication

EP 0429151 A3 19911023 (DE)

Application

EP 90250284 A 19901116

Priority

DE 3938708 A 19891117

Abstract (en)

[origin: EP0429151A2] The service life of, in particular, photoconductors produced using organic compounds and used as intermediate image carriers for photocopiers and laser printers often leaves much to be desired. In order to lengthen it, it is proposed to subject the particular photoconductor to a low-temperature plasma treatment. <IMAGE>

IPC 1-7

G03G 5/06

IPC 8 full level

G03G 5/06 (2006.01)

CPC (source: EP)

G03G 5/06 (2013.01)

Citation (search report)

- [A] PATENT ABSTRACTS OF JAPAN vol. 12, no. 223 (C-507)(3070) 24 Juni 1988, & JP-A-63 18080 (SHARP CO.) 25 Januar 1988,
- IBM TECHNICAL DISCLOSURE BULLETIN. vol. 25, no. 11B, April 1983, NEW YORK US Seiten 6012 - 6013; W.E. Ellis et al.: "Photoconductor manufacture" & JP-A-63 18080
- [A] IBM TECHNICAL DISCLOSURE BULLETIN. vol. 25, no. 11B, April 1983, NEW YORK US Seiten 6012 - 6013; W.E. Ellis et al.: "Photoconductor manufacture"

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